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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/084,148	02/28/2002	Tatsuya Ohguro	220199US2S	4941
22850	7590 07/22/2004		EXAM	INER
OBLON, SPIVAK, MCCLELLAND, MAIER & NEUSTADT, P.C.			FARAHANI, DANA	
1940 DUKE STREET ALEXANDRIA, VA 22314			ART UNIT	PAPER NUMBER
	•		2814	

DATE MAILED: 07/22/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

	<del></del>				
	Application No.	Applicant(s)			
Office Astion Output	10/084,148	OHGURO, TATSUYA			
Office Action Summary	Examiner	Art Unit			
	Dana Farahani	2814			
The MAILING DATE of this communical Period for Reply	tion appears on the cover sheet w	rith the correspondence address			
A SHORTENED STATUTORY PERIOD FOR THE MAILING DATE OF THIS COMMUNICA  - Extensions of time may be available under the provisions of 3' after SIX (6) MONTHS from the mailing date of this communic  - If the period for reply specified above is less than thirty (30) da  - If NO period for reply is specified above, the maximum statuto  - Failure to reply within the set or extended period for reply will,  Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).	TION. 7 CFR 1.136(a). In no event, however, may a ation. 1ys, a reply within the statutory minimum of thi 1y period will apply and will expire SIX (6) MO 1yby statute, cause the application to become A	reply be timely filed  rly (30) days will be considered timely.  NTHS from the mailing date of this communication.  BANDONED (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed of	n 10 May 2004.				
	<u> </u>				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the					
closed in accordance with the practice	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.				
Disposition of Claims					
4) Claim(s) 1-28 is/are pending in the app	Claim(s) 1-28 is/are pending in the application.  4a) Of the above claim(s) 2,3,7-12,14,15 and 27 is/are withdrawn from consideration.  Claim(s) 16-19 is/are allowed.  Claim(s) 1,4-6,13,22,26 and 28 is/are rejected.				
5)⊠ Claim(s) <u>16-19</u> is/are allowed.					
6) Claim(s) 1,4-6,13,22,26 and 28 is/are re					
7) Claim(s) <u>20,21 and 23-25</u> is/are objected	ed to.				
8) Claim(s) are subject to restriction	n and/or election requirement.				
Application Papers	·				
9)☐ The specification is objected to by the E	xaminer.				
10) The drawing(s) filed on is/are: a)		by the Examiner.			
Applicant may not request that any objection					
Replacement drawing sheet(s) including the	- ' '				
11) The oath or declaration is objected to by	· ·	• • •			
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for	foreign priority under 25 LLS C	\$ 110(a) (d) or (f)			
a) ☐ All b) ☐ Some * c) ☐ None of:	loreign priority under 35 0.3.6.	g 119(a)-(d) 01 (l).			
,	numents have been received				
1. Certified copies of the priority do		Application No			
2. Certified copies of the priority do					
3. Copies of the certified copies of t	•	Heceived III tills National Stage			
application from the International		traceived			
* See the attached detailed Office action for	or a list of the certified copies no	i recerveu,			
Attachment(s)	. 🗖				
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftsperson's Patent Drawing Review (PTO-</li> </ol>		Summary (PTO-413) (s)/Mail Date			
3) Information Disclosure Statement(s) (PTO-1449 or PTC		Informal Patent Application (PTO-152)			
Paper No(s)/Mail Date	6)  Other:				

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#### **DETAILED ACTION**

## Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1, 4-6, 13, 22, 26 and 28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nowak et al., hereinafter Nowak (US Patent 6,191,451).

Regarding claims 1, 4, 22, and 26, Nowak discloses in figure 2, a semiconductor device comprising a semiconductor substrate 150; a first conductivity type well area 130 formed in a surface area of the semiconductor substrate; a plurality of element isolation areas 20 formed in the well area; a second conductivity type semiconductor layer 136 formed at a first area of the well area (the area within the area, and at the left side, of an imaginary line drawn through the Vdd electrode down to the bottom portion of the substrate) which is isolated by the element isolation areas, the second conductivity type semiconductor layer configuring a first electrode of a capacitor; a first conductivity type semiconductor layer 138 formed in a second area of the well area (the area within the right-hand-side of the mentioned imaginary line which is drawn through the Vdd electrode), which is isolated by the element isolation areas, the first conductivity type semiconductor layer configuring a second electrode of the capacitor; and a first conductivity type low resistance area 140 provided at a base portion of the well area, which connects the above mentioned first and second area, the low resistance area having a resistive value lower than that of the well area, wherein the low resistance area is not in contact with a depletion layer of a

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junction portion between the second conductivity type semiconductor layer and the well area, and is not in contact with a depletion layer of a junction portion between the first conductivity type semiconductor layer and the well area. Although, Nowak does not disclose the well is in contact with the element isolation areas, it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the length of the isolation regions, since such a modification would have involved a mere change in size of a component. A change in size of a component is generally recognized as being within the level of ordinary skill in the art. *In re Rose, 105 USPO 237 (CCPA 1955)*.

Regarding claims 5 and 6, Nowak renders obvious the claimed invention except for the impurity concentration of the low resistance area. It would have been obvious to one of ordinary skill in the art at the time the invention was made to include these values, since it has been held that discovering an optimum value of a result effective variable involves only routine skill in the art. In re Boesch, 617 F.2d 272, 205 USPO 215 (CCPA 1980).

Regarding claims 13 and 28, note that Nowak discloses the limitation in the claim, as discussed above with regard to claim 1, also discloses a first well area 130; a second well area 134; isolation regions 20; a first electrode, Vdd and region 136 of a second type on the first area (as defined above, in the claim 1 rejection); a second electrode 142 of the first type of the bipolar transistor (comprising regions 136, 132, 130, 134, 142, and 144) formed on the first electrode. Note also Nowak does not discloses a third electrode of the first conductivity type formed in the second area of the substrate, it would have been obvious to make another identical P+ region, and its corresponding isolation region, in the well area 30, since mere duplication of the essential

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working parts of a device involves routine skill in the art. St. Regis Paper Co. V. Bemis Co., 193 USPQ 8.

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3. Claims 7, 10-12, and 27 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nowak as applied to claim 1 above, and further in view of Stolmeijer et al., hereinafter Stolmeijer (U.S. 5,742,090).

Regarding claims 7, 10, and 27, Nowak discloses the limitations in these claims, as discussed above, with regard to claim 1, further disclosing a second well 134. However, Nowak does not disclose a MOS transistor.

Stolmeijer discloses in figure 5 a MOS transistor 20 in an integrated circuit. Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to include a MOS transistor in Nowak's structure in order to make an integrated circuit application which employs both capacitors and MOS transistors (note that in claim 15 a first conductivity type semiconductor layer is one of a source/drain regions of the transistor).

Regarding claims 11 and 12, Nowak in view Stolmeijer renders obvious the claimed invention except for the impurity concentration of the low resistance area. It would have been obvious to one of ordinary skill in the art at the time the invention was made to include these values, since it has been held that discovering an optimum value of a result effective variable involves only routine skill in the art. *In re Boesch*, 617 F.2d 272, 205 USPQ 215 (CCPA 1980).

## Allowable Subject Matter

- 4. Claims 16-19 are allowed.
- 5. The following is a statement of reasons for the indication of allowable subject matter:

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The reason for indication of allowability of claims 16-19 is inclusion therein of the limitations that of the circuitry stated in those claims.

6. Claims 20, 21, and 23-25 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

7. The following is a statement of reasons for the indication of allowable subject matter: the primary reason for indication of allowability of claims 20, 21, and 23-25 is inclusion therein of the limitations of the third layer and the second low resistance areas.

#### conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dana Farahani whose telephone number is (571)272-1706. The examiner can normally be reached on M-F 9:00AM - 6:00PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael M Fahmy can be reached on (571)272-1705. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)308-0956.

D. Farahani

LONG PHAM PRIMARY EXAMINER